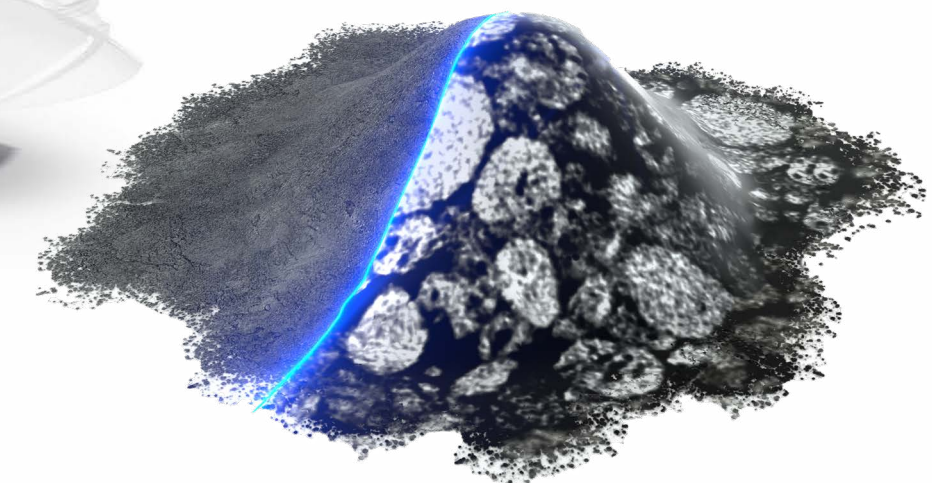
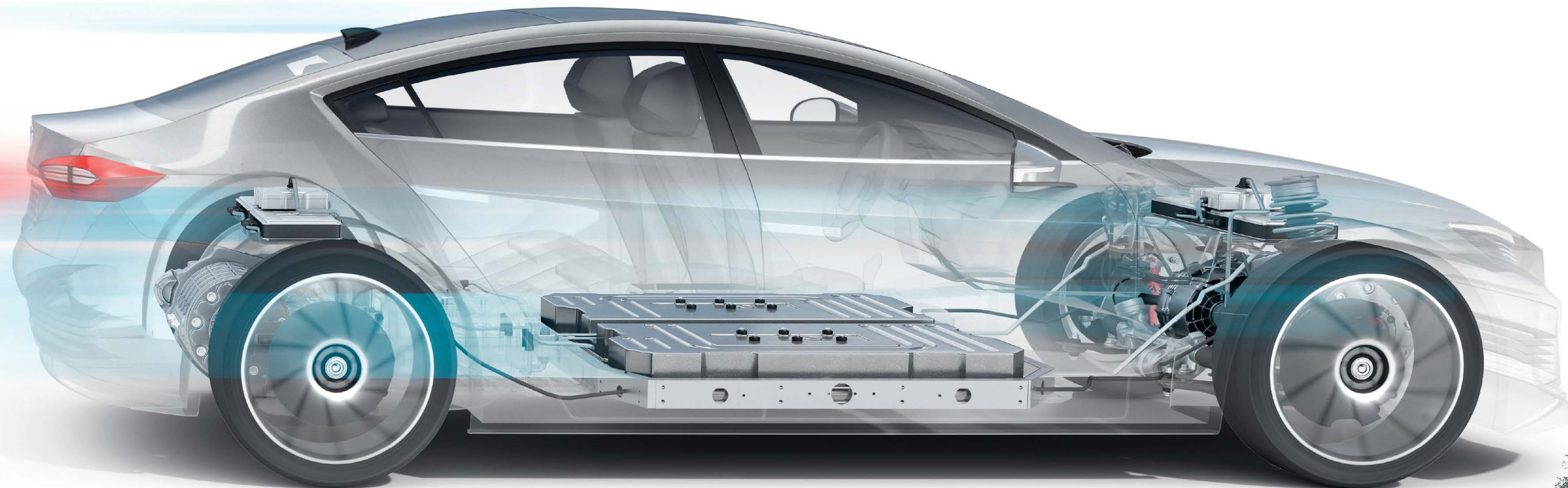


ZEISS eMobility Solutions

# Battery Material Microstructure Analysis by SEM & EDS



Seeing beyond

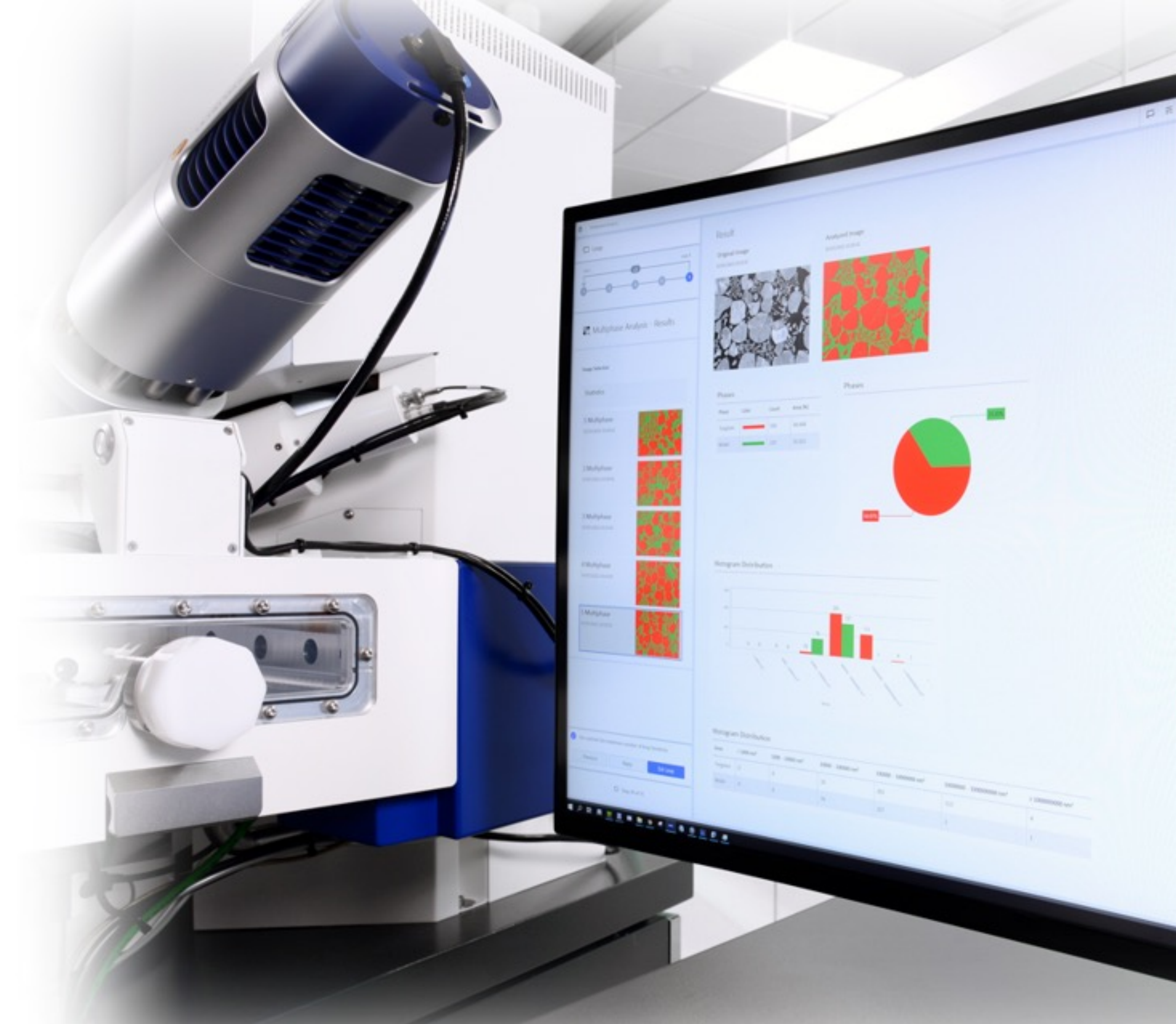




## High quality imaging Battery material R&D by SEM & EDS

Power battery is a crucial component of new energy vehicles (NEV), directly impacting the safety, performance, and production costs of the entire vehicle. Comprising primarily of cathode and anode materials, separators, electrolytes, the development direction of batteries primarily revolves around the exploration of cathode and anode materials that offer high specific capacity, superior safety, low cost, and environmental friendliness.

To develop new-generation battery materials, a series of characterizations and analyses must be conducted throughout the research and development (R&D) process. ZEISS provides scanning electron microscopes (SEM) and energy dispersive spectrometer (EDS) as research tools for battery microstructure analysis.





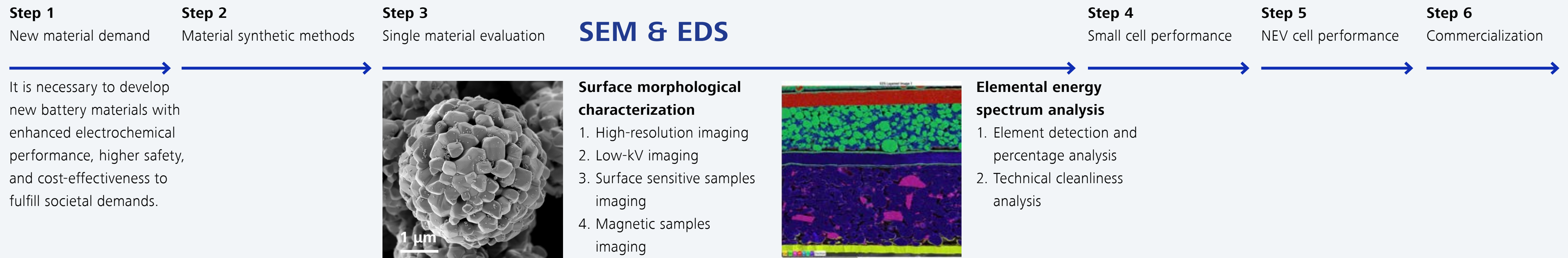
# Ensuring quality of raw materials

## Evaluation with SEM & EDS

The battery production process encompasses material R&D, the electrode manufacturing, cell assembly, and module packaging. Among these steps, the quality of battery materials, including geometric morphology, particle size distribution, and composition and phase structure of microscopic regions, is directly linked to the overall vehicle performance and safety. SEM are commonly used for observing material surface morphologies, and EDS can be paired with SEM to conduct qualitative or quantitative analysis of elements present in minute areas. These solutions provide crucial microscopic information for the design, optimization, and performance enhancement of battery materials.

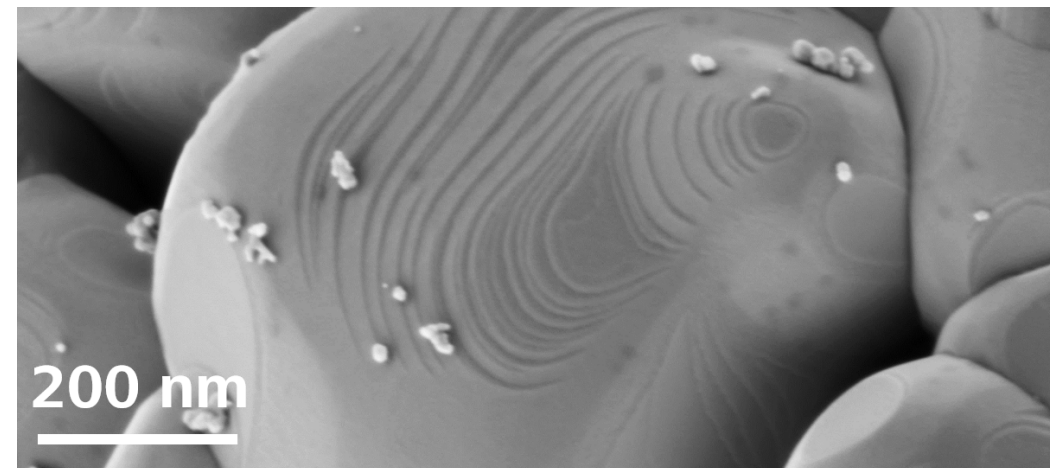


### R&D and production process evolution of NEV battery



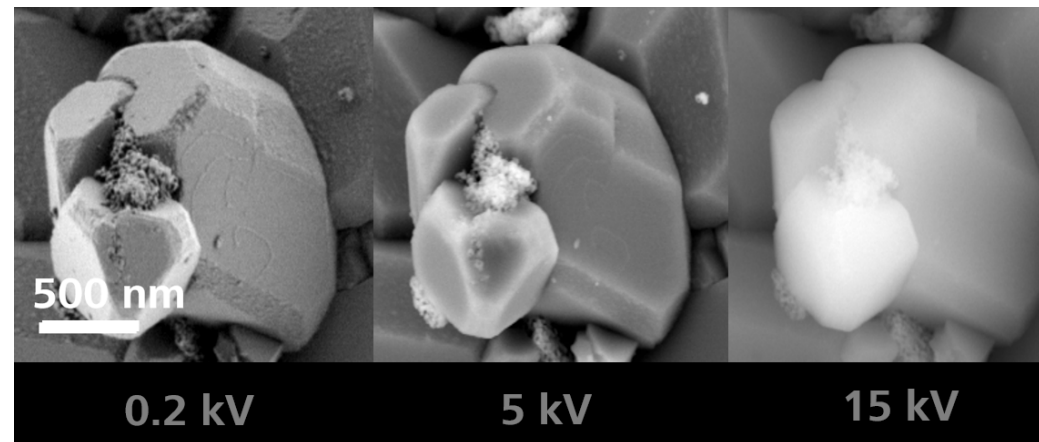


## Application areas of SEM & EDS



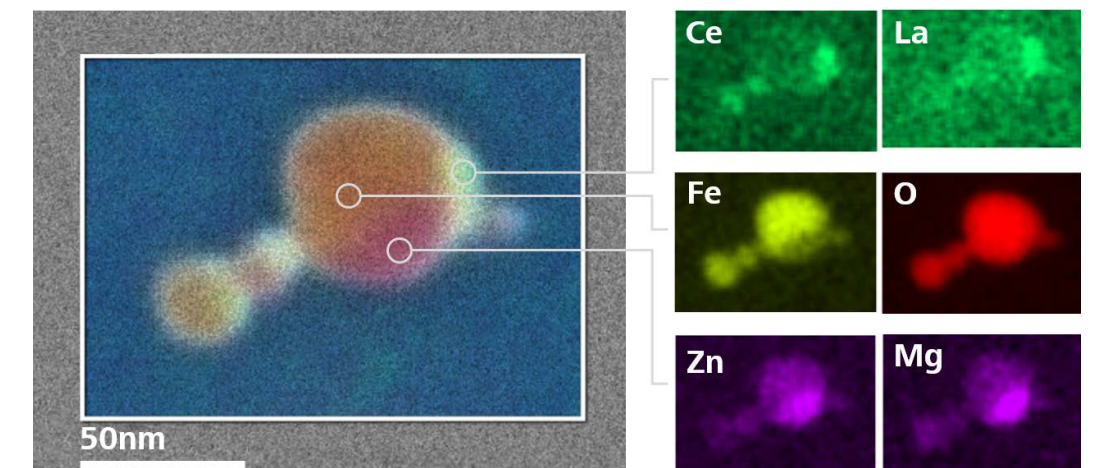
### High-resolution imaging

- Observation of material micromorphology
- Material category and structure identification



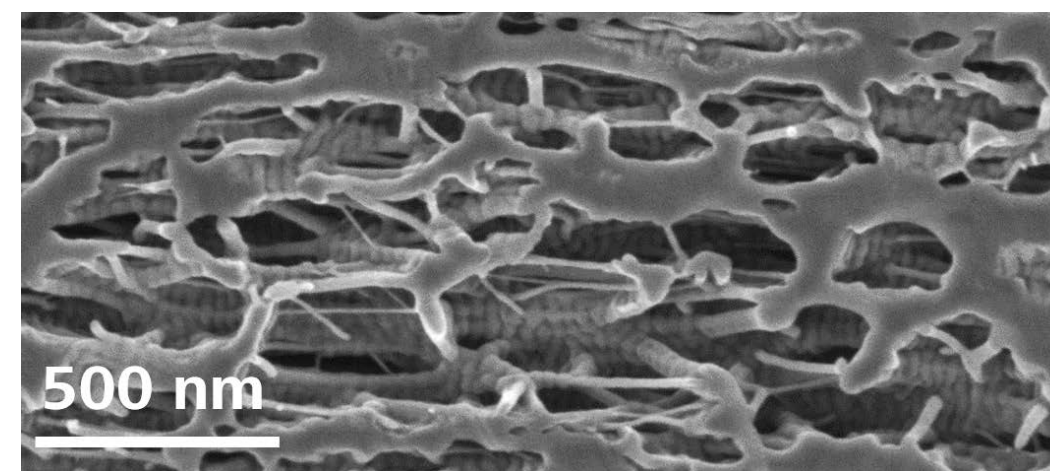
### Low-kV imaging

- Extreme surface details obtaining
- Avoidance of material surface charging



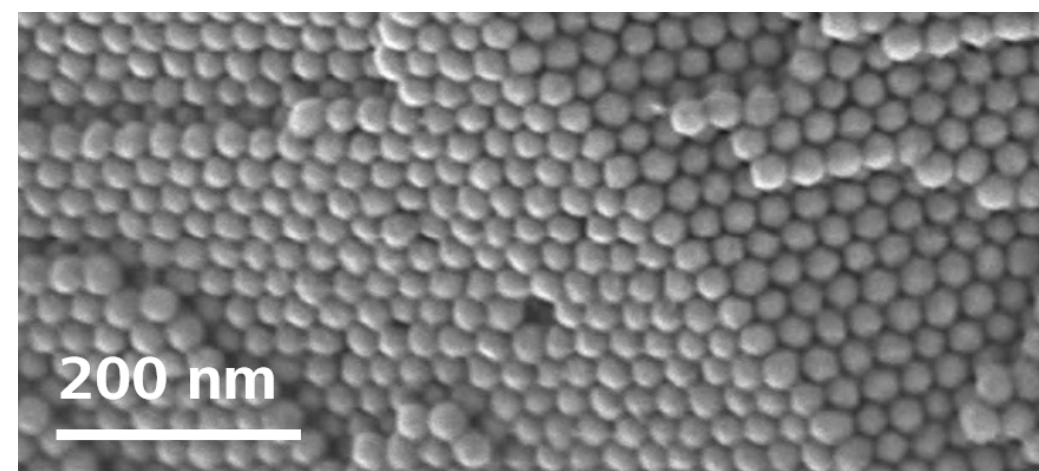
### Element detection and percentage analysis

- High resolution EDS analysis on non-conductive samples
- Low vacuum / low kV EDS analysis



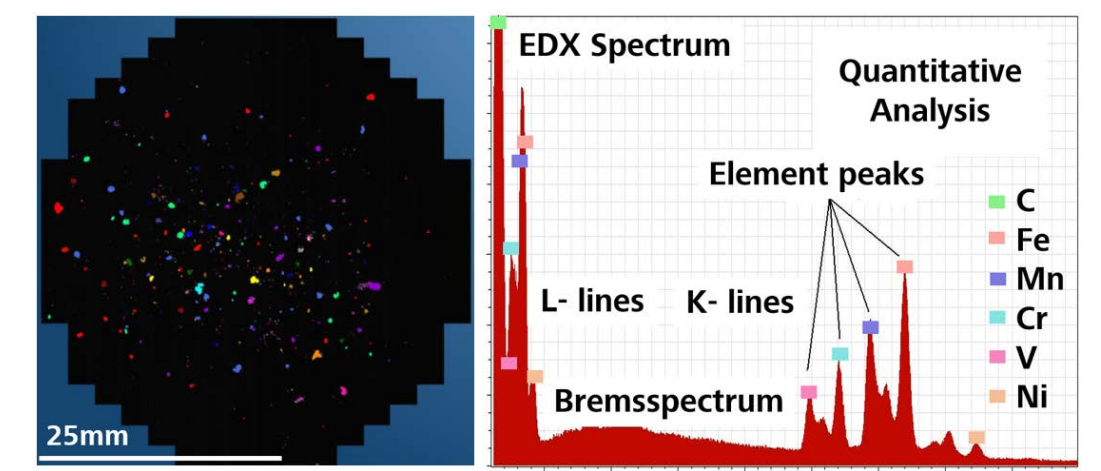
### Surface sensitive samples imaging

- Microscopic imaging of high molecular polymers
- Sub-Nanometer imaging of Thin Films



### Magnetic samples imaging

- Observation of iron, cobalt, nickel and their metal oxides
- Observed directly without degaussing

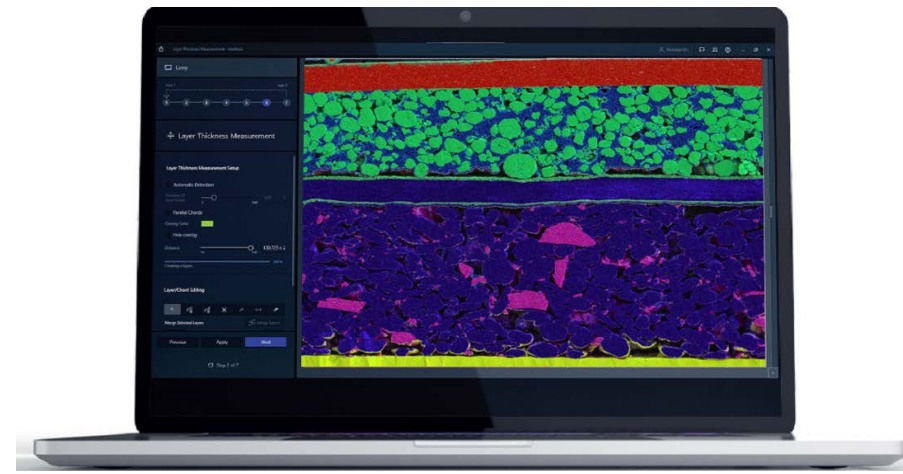


### Technical cleanliness analysis

- Particle classification on the basis of elemental composition
- Correlative Automated Particle Analysis (CAPA)



## Value proposition of ZEISS solution



### Excellent imaging results

- Acquire great imaging results and accurate elemental chemistry information
- Deepen understanding of battery materials



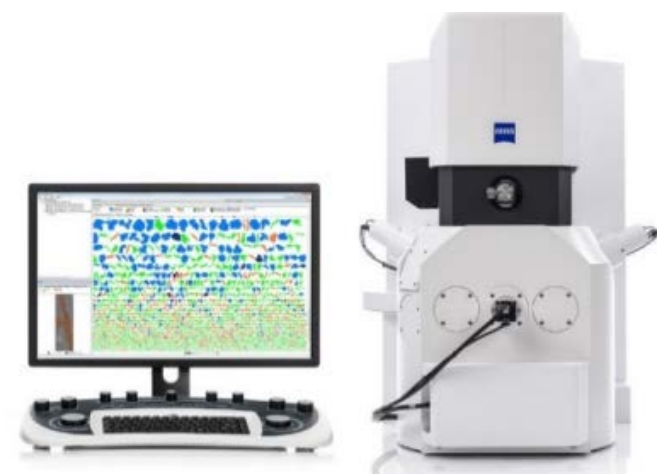
### Friendly for both expert and novice users

- For expert users: enable full control over the microscope with full access to all functions and parameters available
- For novice users: empower users to generate excellent images, regardless of skill level



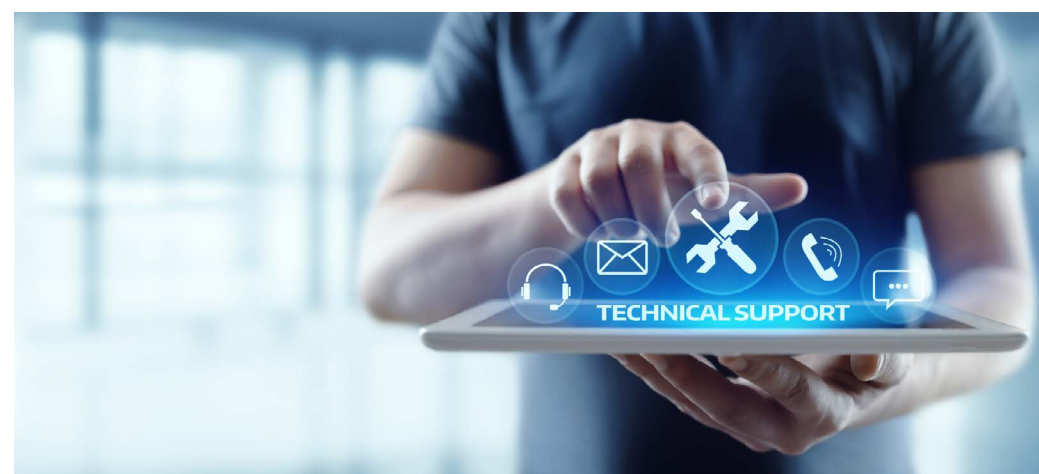
### Increase efficiency

- Flexible and convenient operation to save time
- Highly intelligent to improve efficiency



### Reliable and repeatable data

- Reliable user-independent and reproducible results
- Reach highest quality and fulfill industry standards like VDA 19.1



### Cost saving

- Easy to use: drastically reduce training costs
- Long service life and high durability



### Speed up workflow

- Achieve high throughput for simple automated imaging workflows
- Satisfy sub-nanometer imaging, analytics and sample flexibility

# Recommended portfolio

## Best qualified SEM to support industrial quality

ZEISS EVO



<b>Resolution</b>	3 nm @ 30 kV - SE 8 nm @ 3 kV - SE
<b>Magnification</b>	5x to 1,000,000x
<b>Probe current</b>	0.5 pA to 5 µA
<b>Acceleration voltage</b>	0.2 - 30 kV, step: 10V

**Benefits:**



- High cost performance
- High probe current stability
- High resolution storage: 32000 × 24000 pixels
- Correlation microscope: SEM & LM

## Field emission SEM technology with an excellent user experience

ZEISS Sigma



<b>Resolution</b>	0.7 nm @ 15 kV* 1.2 nm @ 1 kV*
<b>Magnification</b>	10x to 1,000,000x
<b>Probe current stability</b>	0.2%/h
<b>Acceleration voltage</b>	0.02 - 30 kV, step: 10V

\* The highest indicator in the series

**Benefits:**



- High probe current stability
- High resolution storage: 32000 × 24000 pixels
- Excellent low-kV imaging
- Correlation microscope: SEM & LM

## Field emission SEM for the highest demands in imaging and analytics

ZEISS GeminiSEM



<b>Resolution</b>	0.5 nm @ 15 kV* 0.8 nm @ 1 kV*
<b>Magnification</b>	1x to 2,000,000x
<b>Probe current stability</b>	0.2%/h
<b>Acceleration voltage</b>	0.02 - 30 kV, step: 10V

\* The highest indicator in the series

**Benefits:**



- High probe current stability
- High resolution storage: 32000 × 24000 pixels
- Excellent low-kV imaging
- Correlation microscope: SEM & LM



**38**

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## Global Metrology Network

Our global service network provides easy access to ZEISS expertise around the world. We use local teams to ensure a swift response and reduced downtime. Make your operations even more secure and reliable with ZEISS.

**Find your perfect solution today.**  
Contact our global experts.

